



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application Serial No. ....10/643,680  
Filing Date .....August 18, 2003  
Confirmation No. .... 4607  
Inventor.....Brenda D. Kraus et al.  
Assignee .....Micron Technology, Inc.  
Group Art Unit ..... 1762  
Examiner ..... Brian K. Talbot  
Attorney's Docket No. .... MI22-2310  
Customer No. .... 021567  
Title: Atomic Layer Deposition Methods of Forming Conductive Metal Nitride  
Comprising Layers

**RESPONSE TO OCTOBER 12, 2006 OFFICE ACTION**

To: Mail Stop Amendment  
Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

**VIA EXPRESS MAIL**

From: Mark Matkin (Tel. 509-624-4276; Fax 509-838-3424)  
Wells St. John P.S.  
601 West First Avenue, Suite 1300  
Spokane, WA 99201-3828

Responsive to the Office Action dated October 12, 2006, Applicant  
amends and remarks as follows:

**AMENDMENTS**

01/16/2007 AWONDAF1 00000115 10643680

01 FC:1201

800.00 OP

**EV979437262**